



Molecular Imprints, Inc.

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**MOLECULAR IMPRINTS INSTALLS TOOLS  
IN VARIOUS NATIONAL LABS & RESEARCH CENTERS**

AUSTIN, TX, June 21, 2005 – Molecular Imprints, Inc. (MII), the world leader in Step and Flash Imprint Lithography (S-FIL™) technology, announces sales of its Imprio™ 55 system, into Lawrence Berkeley National Lab's Molecular Foundry in California, the University of Texas at Austin (UT-Austin), and Pennsylvania State Nanofabrication Facility (PSU Nanofab), and a sale of an Imprio 100 tool to the Microelectronics Research Center (MRC) at UT-Austin.

Norm Schumaker, MII's President and CEO said: "We are pleased to have these organizations as our customers. Their research objectives and those of Molecular Imprints are closely aligned and we look forward to a long and beneficial relationship."

The Molecular Foundry is a user facility for the design, synthesis and characterization of nanoscale materials. This facility provides instruments and techniques dedicated to state-of-the-art lithographic and thin-film processing relevant to the integration of advanced semiconductor nanofabrication technologies with chemical and biological nanosystems.

The PSU Nanofab is a professionally staffed class 10 clean room facility, providing a full range of processing capabilities for substrates as large as six inches in diameter. The Penn State Nanofab offers expertise in "top-down" and "bottom up" nanofabrication.

Dr. Grant Willson's research group at the University of Texas purchased the Imprio 55 to support nanofabrication projects and conduct materials research. The MRC will be using the Imprio 100 as a teaching tool and for research into integrated circuit devices, optoelectronics, nanophotonics, and biosensors.

**About Molecular Imprints Inc.**

Molecular Imprints, Inc. (MII) is a global developer and manufacturer of nano-lithography systems for high resolution and for 3-dimensional pattern replication. The company has commercialized the unique Step and Flash Imprint Lithography technology (S-FIL), which is a simple step and repeat, room temperature, low pressure, nano-imprint process that has demonstrated sub-20 nanometer resolution. Molecular Imprints provides enabling lithography systems and technology for manufacturing applications in the areas of: nano-devices, micro structures, advanced packaging, bio-devices, optical components and semiconducting devices. For more information, visit: [www.molecularimprints.com](http://www.molecularimprints.com).

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